



Multibhashi



BASIC GREETINGS



Class Objective

To learn the basic greetings in
Hindi





Types of greetings

- Formal
- Informal
- Party/Festive
- Slang



Concept A : Informal Greetings - Below are a few informal greetings

- Hello- Namaste How are you? - Aap kaise hain? आप कैसे हैं
- I'm good - Main achcha hoon. मैं अच्छा हूँ And you? - Aur Aap? और आप?
- How's everything else? - Baki sab kaise chal raha hai? बाकी सब कैसे चल रहा है?
- Everything is fine- Baki sab thik hai. बाकी सब ठीक है



Concept B : Formal Greetings - Below are a few informal greetings

- Good morning - Suprabhat सुप्रभात
- Good night - Shubh ratri शुभ रात्रि
- Have a good day/Have a nice day - Aap ka din accha rahe/Aap ka din accha ho आप का दिन अच्छा रहे / आप का दिन अच्छा हो
- Thank you - Dhanyavad धन्यवाद Welcome (When used as a response to
- Thank you) - Koi baat nahi कोई बात नहीं

Concept B : Formal Greetings - Below are a few informal greetings

Welcome (To welcome someone)- Aapka swagat hai आपका स्वागत है

Meet you later- Baad mein milte hain/Phir milenge बाद में मिलते हैं/ फिर मिलेंगे

It was nice meeting you- Aap se milkar khushi hui/Aap Se mil kar achcha laga आप से मिलकर खुशी हुई/आप से मिल कर अच्छा लगा

THE UNIVERSITY OF CHICAGO
INSTITUTE OF TECHNOLOGY
DEPARTMENT OF ELECTRICAL ENGINEERING
EE-561: ADVANCED TOPICS IN SIGNAL PROCESSING
LECTURE 1: INTRODUCTION TO THE COURSE

1.1 COURSE OBJECTIVES

1.2 COURSE STRUCTURE

1.3 COURSE MATERIALS

1.4 COURSE SCHEDULE

1.5 COURSE FACULTY

1.6 COURSE CONTACTS

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LECTURE 1: INTRODUCTION TO ADVANCED TOPICS

TOPIC 1: ADVANCED TOPICS IN SIGNAL PROCESSING

TOPIC 2: ADVANCED TOPICS IN SIGNAL PROCESSING

TOPIC 3: ADVANCED TOPICS IN SIGNAL PROCESSING

TOPIC 4: ADVANCED TOPICS IN SIGNAL PROCESSING

TOPIC 5: ADVANCED TOPICS IN SIGNAL PROCESSING

TOPIC 6: ADVANCED TOPICS IN SIGNAL PROCESSING

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